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## JC18 RSC'd FCT/FTO 29 SEP 2005

**PATENT** 

ATTORNEY DOCKET NO.: 046124-5429

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	)
Seiichi NAGATA	) Examiner: Unassigned
Application No.: <b>NEW</b> (based on National stage of PCT Application No. PCT/JP2004/004711 filed March 31, 2004	) Group Art Unit: Unassigned ) )
Filed: September 29, 2005	)
For: SILICON SUBSTRATE AND METHOD OF FORMING THE SAME	) )
Commissioner for Patents U.S. Patent and Trademark Office Customer Window, MAIL STOP PCT Randolph Building Alexandria, VA 22314	

## **PRELIMINARY AMENDMENT**

Prior to examination on the merits, please amend the above-identified application as follows.

Sir: